

Προσομοιώσεις *ab initio* και Μοριακή Δυναμική σε νανοδομές: φαινόμενα ατομικής κλίμακας.



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Outline

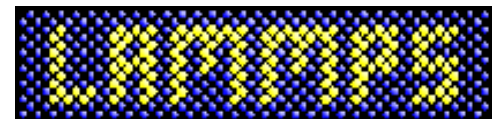
Methodology

1. Edge and screw dislocations of GaN => Thermal Cond.
2. GaN nanoclusters formation in a-SiO₂ matrix
3. Defects in novel 2D materials-ARSENENE
4. Ab initio investigation of the AlN:Er system



Methodology

Molecular dynamics-Interatomic potentials



- LAMMPS MD simulator
- Bond-order many body Tersoff-Brenner interatomic potentials
- Embedded-atom method interatomic potentials

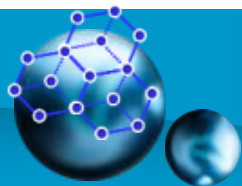
ab-initio methods

- Abinit code with modified Troullier-Martins pseudopotentials
- VASP code with Projector Augmented Wave pseudopotentials.
- AIMPRO code uses Hartwigsen-Goedecker-Hutter pseudopotentials and a Gaussian basis set to describe the Kohn-Sham wave functions of the valence electrons.

abinit

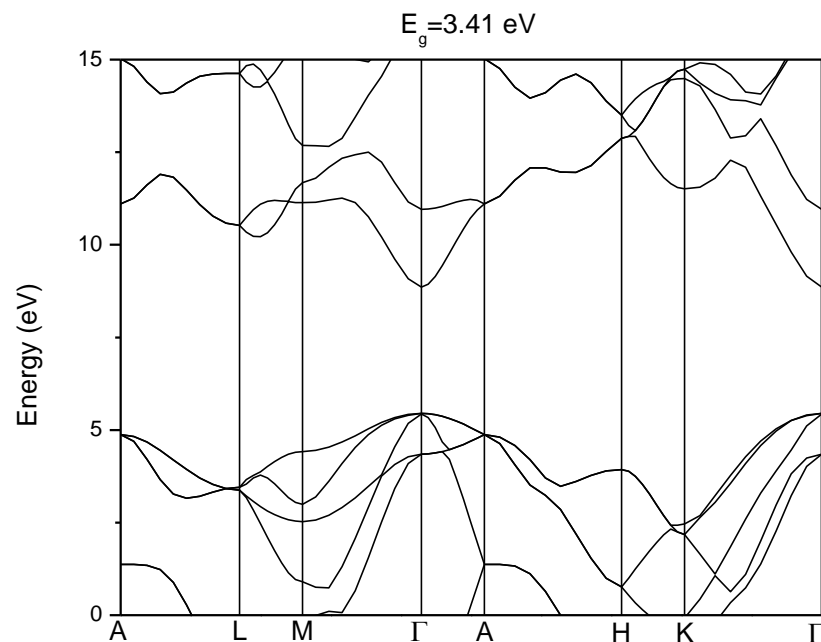
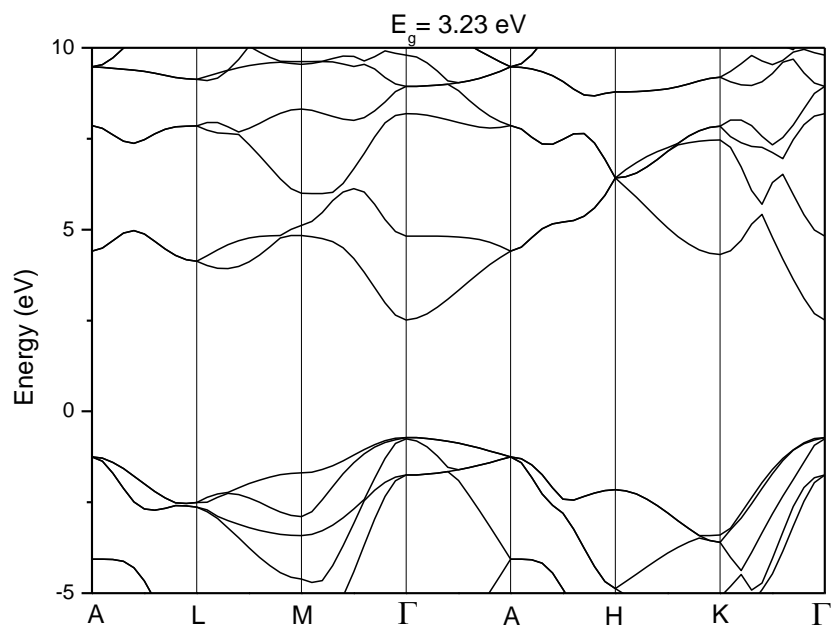
b-initio
VASP
package
simulation
Vienna

AIMPRO.abinitio



Bulk Calculation

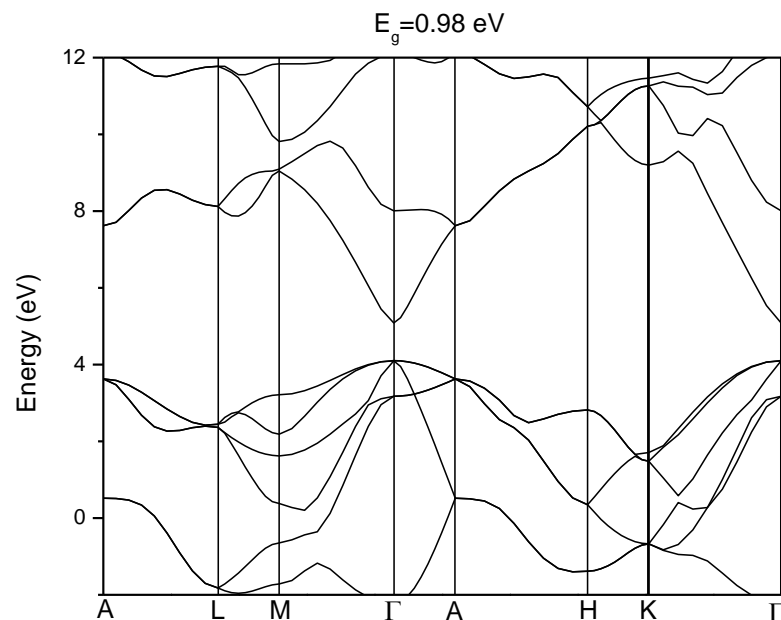
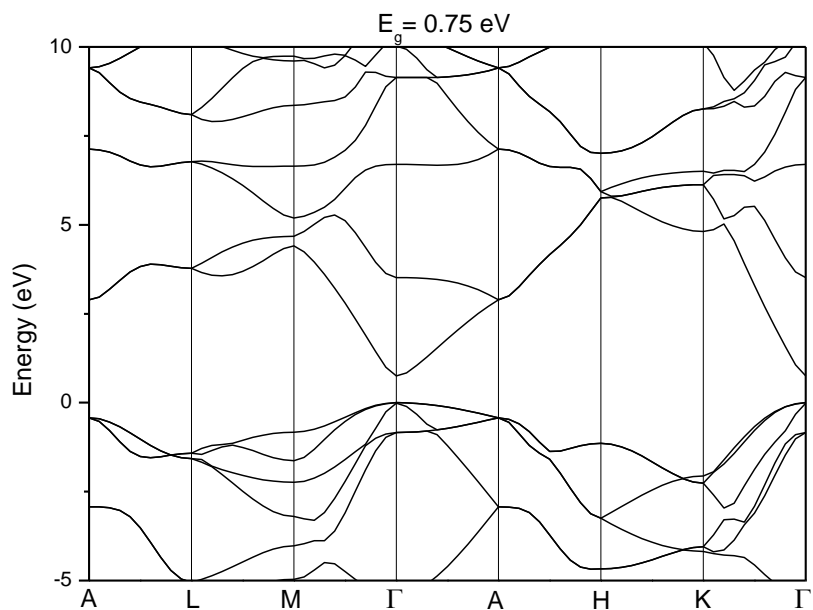
GaN			
	ABINIT modified Troullier-Martins	AIMPRO modified HGH	AIMPRO HGH NLCC
a	3.226	3.073	3.157
c	5.236	5.005	5.15
c/a	1.6231	1.6287	1.6313
Bandgap (eV)	3.23	3.41	2.58

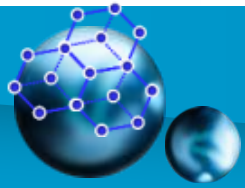




Bulk Calculation

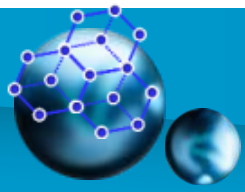
		InN		
		ABINIT modified Troullier-Martins	AIMPRO modified HGH	AIMPRO HGH NLCC
a		3.554	3.406	3.544
c		5.737	5.514	5.721
c/a		1.6142	1.6189	1.6143
Bandgap (eV)		0.75	0.98	0.02





PART I:

**The influence of edge and screw dislocations
of wurtzite GaN on the thermal conductivity**



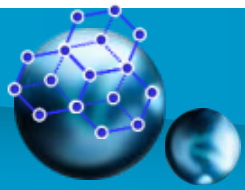
Dislocations and thermal properties

➤ Dislocations and GaN:

- ❖ Phonon scattering processes due to dislocations (Holland model)
- ❖ Phonon relaxation time related to the Burgers vector (scattering direction and orientation of the dislocation: perpendicular and in random orientation)
- ❖ “Thermal Transport along (screw) dislocation line in Silicon Carbide” (10-25% reduction)
- ❖ “Atomic simulation of the size and orientation dependences of TC in GaN nanowires”

Applications

- ❖ Design materials of high-temperature electronics and thermoelectric applications
- ❖ Few materials exhibit high thermal conductivity at reduced dimensions, GaN is one of them
- ❖ GaN: next generation of high frequency and high power transistors
- ❖ GaN: capable of operating in high temperatures
- ❖ GaN: optoelectronics and photonic devices (desire high TC)



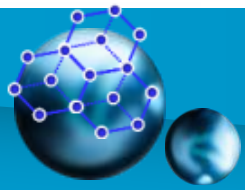
Equilibrium Molecular Dynamics:

- **LAMMPS code, EMD method**

- Green-Kubo formula for the autocorrelation function of the heat flux in z-direction
- Initial structures are relaxed with the conjugate gradient energy minimization algorithm
- EMD: repeat simulation set-up for each system 10 times
- Obtain thermalisation NVT ($T=300\text{K}$) for 200 ps, equilibration NVE in 2 ns, then averaging NVE for 4-5 ns
- Periodic boundary conditions in the all directions
- Interatomic potential reproduce well the bulk TC 160 W/mK

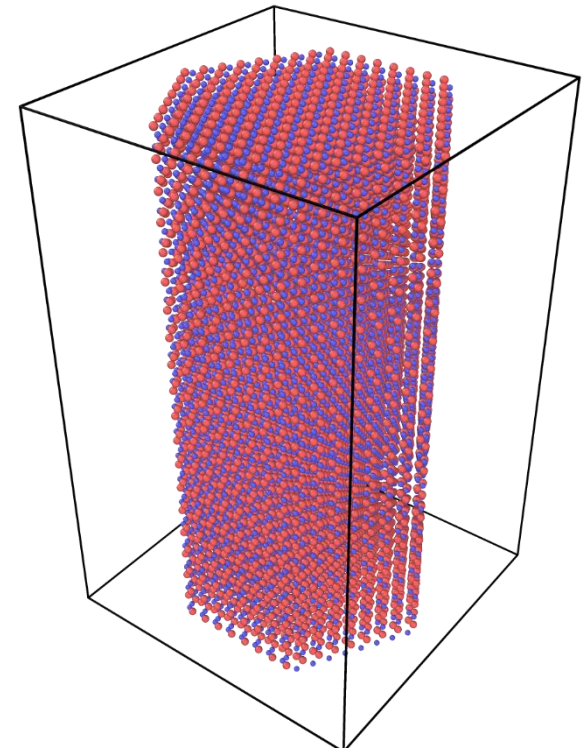
Stillinger-Weber, PRB **31**, 5262 (1985)

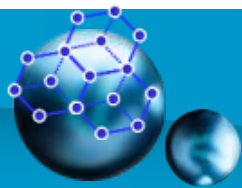
- Simulation box: 6nm x 6nm x 10nm (1nm empty space)



Modelling nanowires I:

- Pristine nanowires with different cross sections
- Square cross-section for the study of dislocations with cross-section 4nmx4nm, length 10nm
- NWs with dislocations
 - ❖ 3 types of “perfect” edge dislocations (4, 5/7, 8) and
 - ❖ 2 of screw “perfect” dislocations (S6,D6)
 - ❖ “perfect” dislocation $b=1$ (a or c)
- Lattice constants $a = b = 3.189 \text{ \AA}$, $c = 5.214 \text{ \AA}$





Modelling nanowires II:

Three types of dislocations

a-type $\mathbf{b} = 1/3 \langle 11-20 \rangle$

c-type $\mathbf{b} = [0001]$

(a+c)-type $\mathbf{b} = 1/3 \langle 11-23 \rangle$

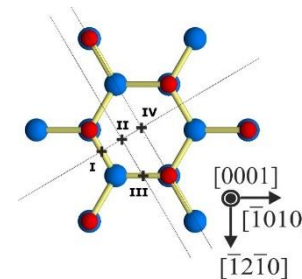
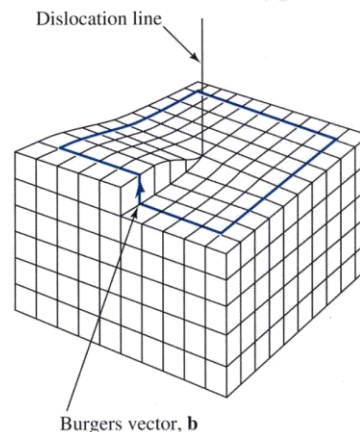
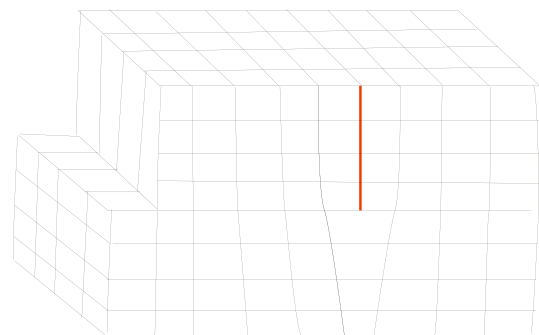
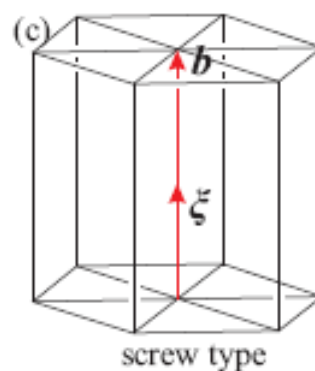
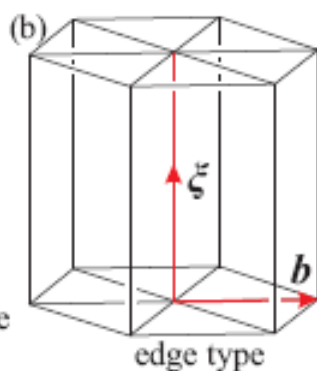
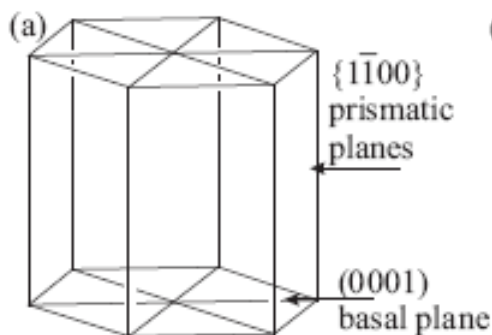
$\mathbf{l} = [0001]$
 edge
 screw
 mixed

$\mathbf{l} = [11-20]$ Line-direction

screw, mixed (60°)

edge

mixed

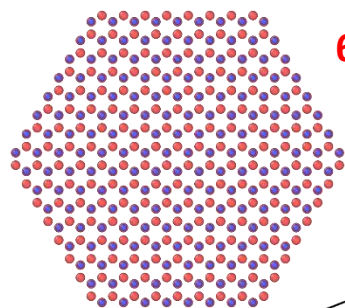


- 90% of dislocations in III-V has line-direction the $[0001]$,
- We model this dislocation line
- Edge: $\xi \perp \mathbf{b}$,
- Screw: $\xi \parallel \mathbf{b}$



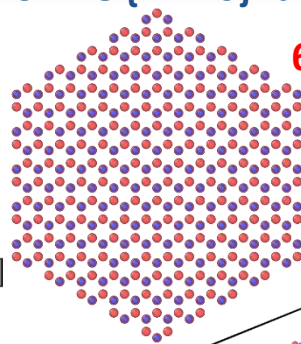
I. GaN NWs with different orientations of the facets and cross-sections

Nanowire {10-10} facets



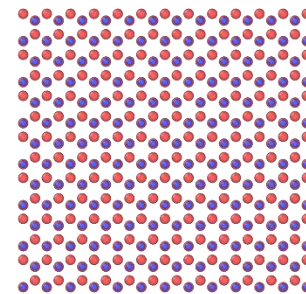
66 ± 6 W/mK

Nanowire {11-20} facets

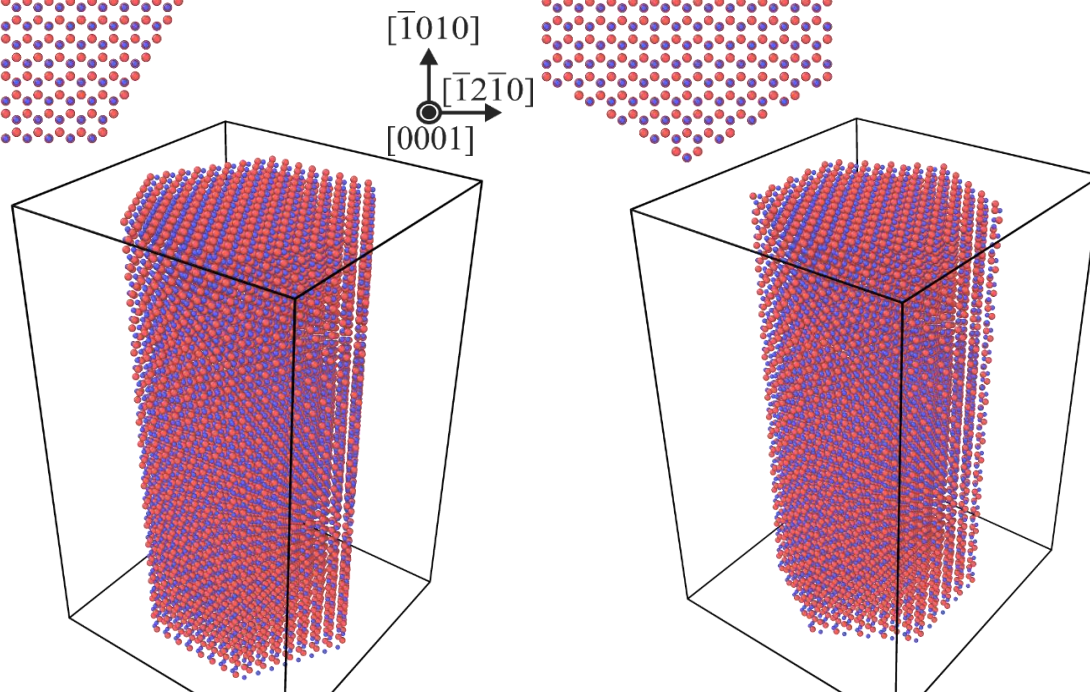


69 ± 6 W/mK

Nanowire {11-20} and {10-10} facets



49 ± 3 W/mK



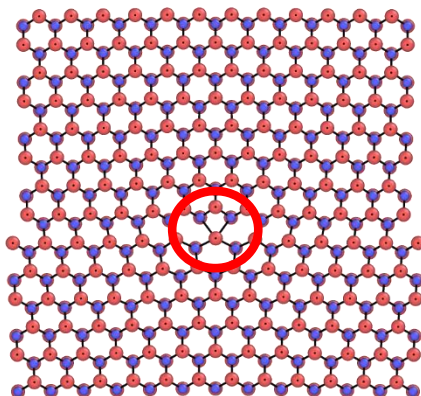
$[\bar{1}010]$
 $[\bar{1}2\bar{1}0]$
 $[0001]$

- Better relaxed free surfaces for the square cross-sections
- Better accommodation of strain of dislocations (avoid numerous edges between facets)



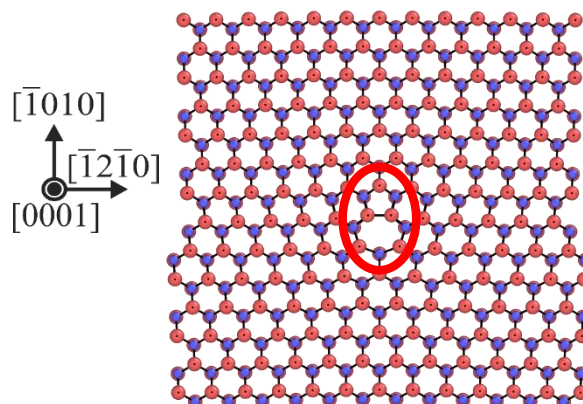
II. GaN with edge dislocations: 4, 5-7, 8

a-edge dislocation:
OVER-coordinated atomic column
4-atom ring configuration



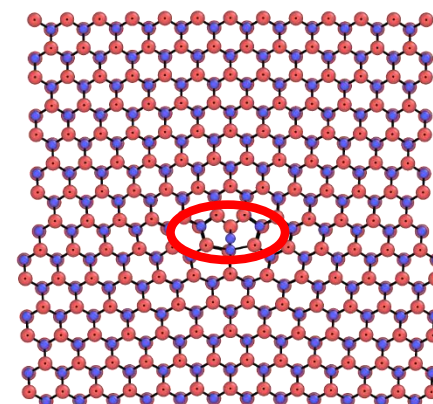
Edge4: 38 ± 4 W/mK

a-edge dislocation
Formation of Ga-Ga and N-N “wrong” bonds
5/7-atom rings configuration



Edge5/7: 42 ± 5 W/mK

a-edge dislocation
LOW-coordinated atomic column
8-atom ring configuration



Edge8: 51 ± 4 W/mK

$TC_{Edge4} < TC_{Edge5/7} < TC_{Edge8} \sim TC_{NWs}$ without dislocations

Explanation with the bonds

Edge4: all bonds are covalent, high stress

Edge5/7: wrong bonds, metallic bonds (Ga-Ga, N-N), less stress

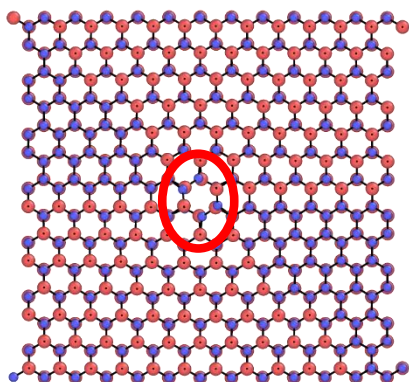
Edge8: presence of dangling bonds, less stress

- Impact of dangling and metallic bonds on TC
- Impact of stress on TC



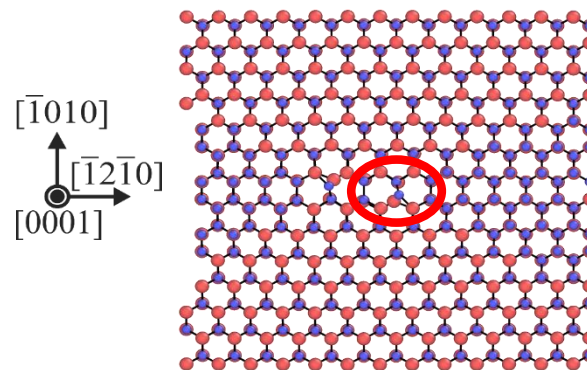
III. GaN with screw dislocations: S6, D6

c-screw dislocation:
Single six-atom ring

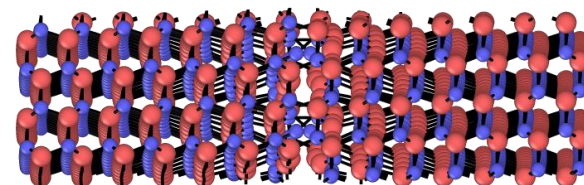
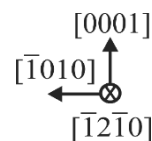
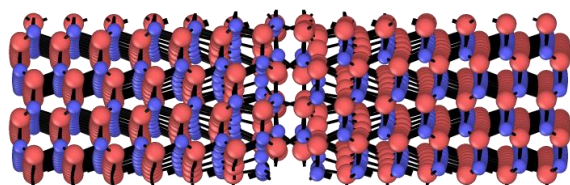
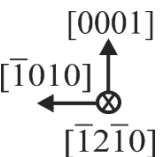


ScrewS6: 20 ± 1 W/mK

c-screw dislocation
Double six-atom ring: two fully coordinated six atom rings
with Ga-Ga and N-N “wrong” bonds
Double six-atom ring



ScrewD6: 28 ± 2 W/mK



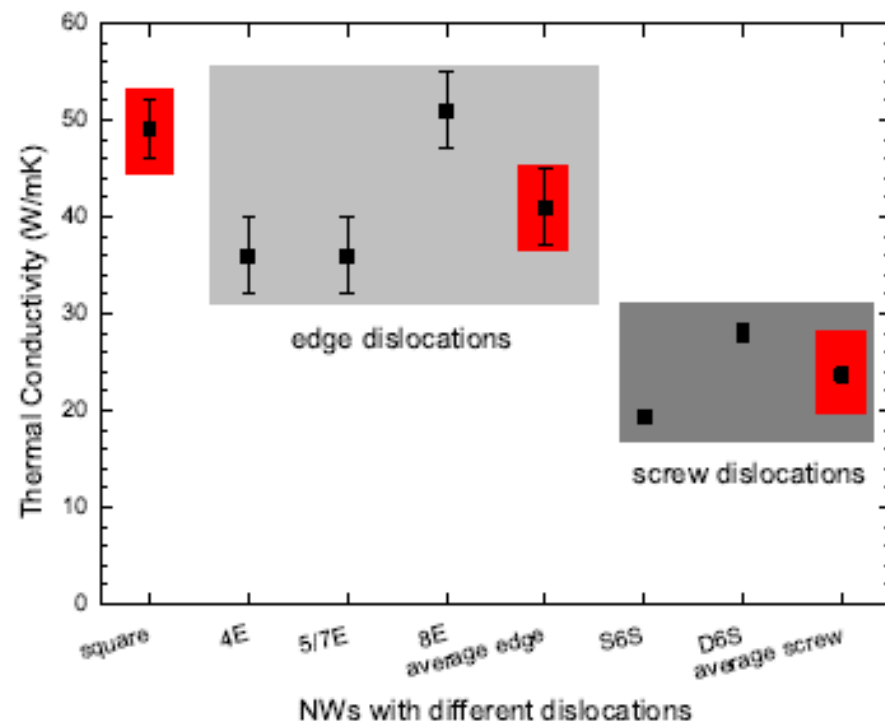
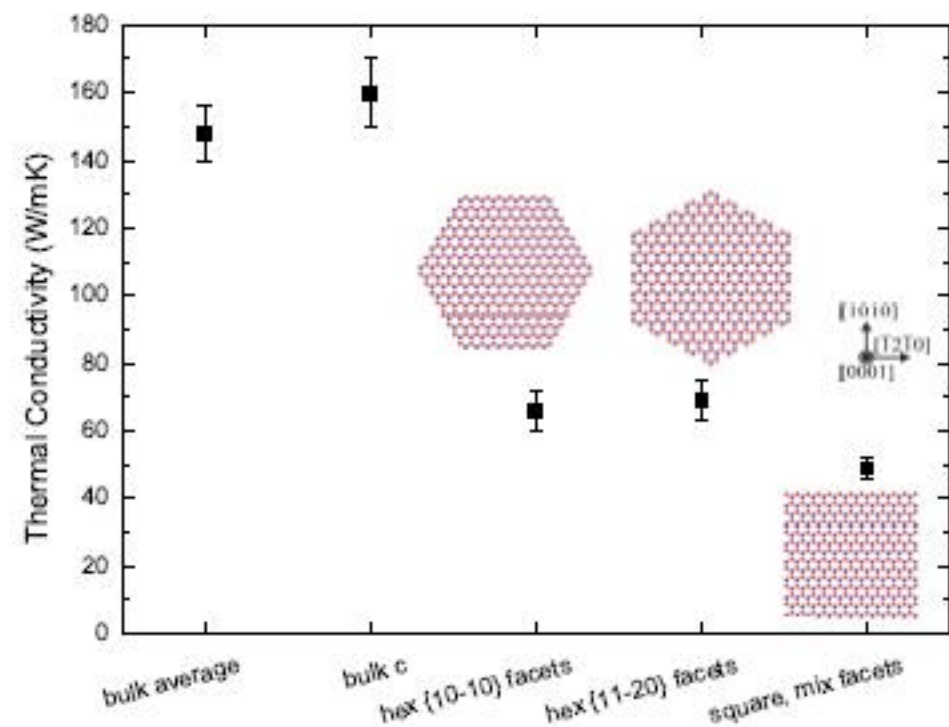
TC_ScrewS6 < TC_ScrewD6
Explanation with the bonds

ScrewS6: all bonds are covalent, high stress

ScrewD6: wrong bonds, metallic bonds (Ga-Ga, N-N), less stress



IV. Screw .vs. Edge dislocations



Thermal conductivity calculated with the EMD method for the bulk GaN (all directions and c-direction), and for GaN nanowires with different external free surfaces facets and cross-section shapes.

Thermal conductivity for pristine nanowires and nanowires containing difference types of dislocations. There are three sub-types of edge dislocations and two sub-types of screw dislocations.



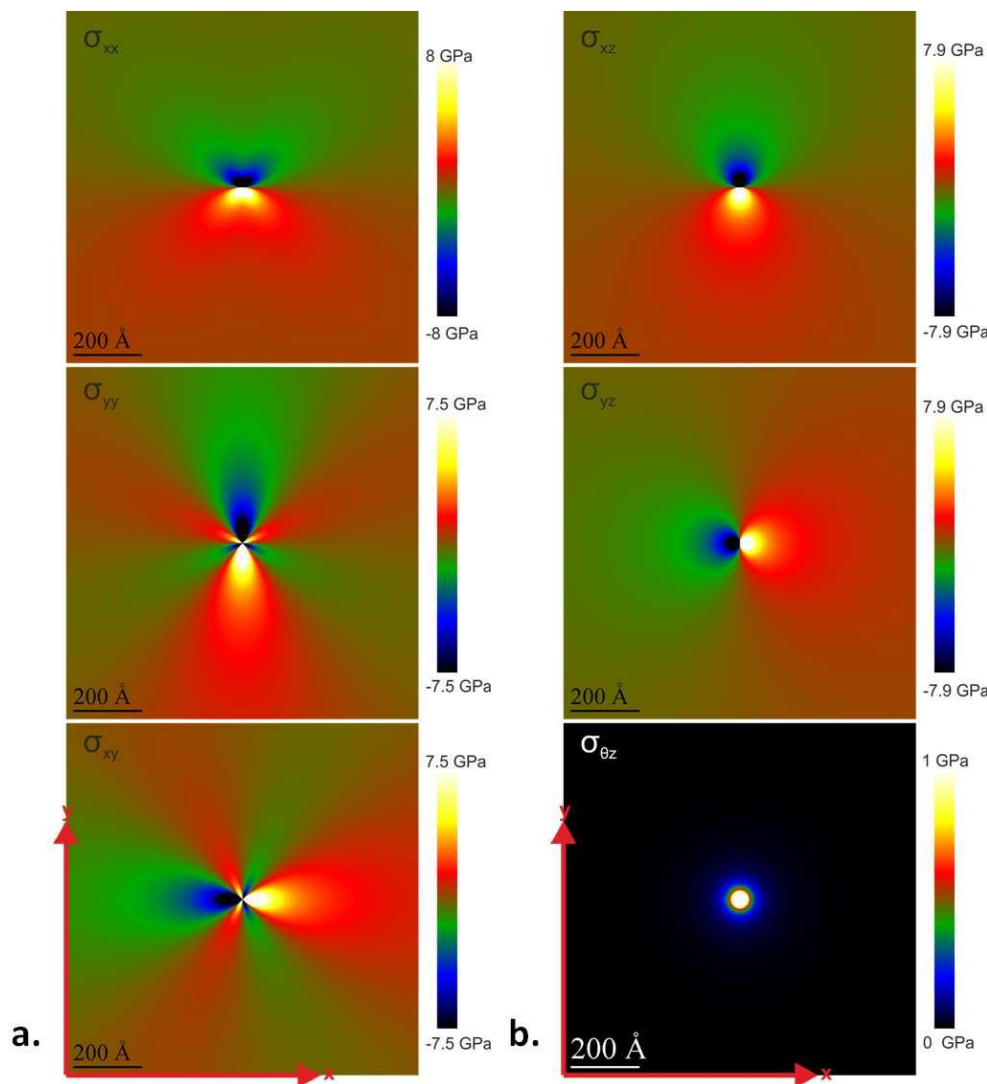
IV. Edge .vs. Screw dislocations

$$\sigma_{xz} = \sigma_{zx} = \sigma_{yz} = \sigma_{zy} = 0$$

$$\sigma_{xx} = -\frac{Gb}{2\pi(1-\nu)} y \frac{3x^2 + y^2}{(x^2 + y^2)^2}$$

$$\sigma_{yy} = \frac{Gb}{2\pi(1-\nu)} y \frac{x^2 - y^2}{(x^2 + y^2)^2}$$

$$\sigma_{xy} = \sigma_{yx} = \frac{Gb}{2\pi(1-\nu)} x \frac{x^2 - y^2}{(x^2 + y^2)^2}$$



$$\sigma_{xx} = \sigma_{yy} = \sigma_{zz} = \sigma_{xy} = \sigma_{yx} = 0$$

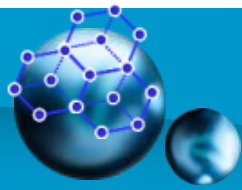
$$\sigma_{xz} = \sigma_{zx} = -\frac{Gb \sin \theta}{2\pi r} = -\frac{Gb}{2\pi} \frac{y}{x^2 + y^2}$$

$$\sigma_{yz} = \sigma_{zy} = \frac{Gb \cos \theta}{2\pi r} = \frac{Gb}{2\pi} \frac{x}{x^2 + y^2}$$

Taking into account that in cylindrical polar coordinates:

$$\sigma_{\theta z} = -\sigma_{xz} \sin \theta + \sigma_{yz} \cos \theta$$

$$\sigma_{\theta z} = \sigma_{z\theta} = \frac{Gb}{2\pi r}$$



IV. Screw .vs. Edge dislocations

	TC(W/mK)
Bulk GaN	160±5
GaN NW	49±3
GaN NW Edge4	38±4
GaN NW Edge5/7	42±5
GaN NW Edge8	51±4
GaN NW ScrewS6	20±2
GaN NW ScrewD6	28±1

Average
44 W/mK
0-22% reduction

Average
24 W/mK
43-60% reduction

Using linear elasticity theory, the strain energy of a dislocations is:

$$E_{total} = E_{elastic} + E_{core}$$

with

$$E_{elastic} = A \ln(R/r_0)$$

$$A = Kb^2/4\pi$$

(K:energy factor, b: Burgers vector)

$$K_{edge} = C_{11}^2 - C_{12}^2 / 2C_{11}$$

$$K_{screw} = C_{44}$$

Finally the prelogarithmic factors for both dislocations:

$$A_{edge} = 0.77eV/A, \quad A_{screw} = 1.38Ev/A$$

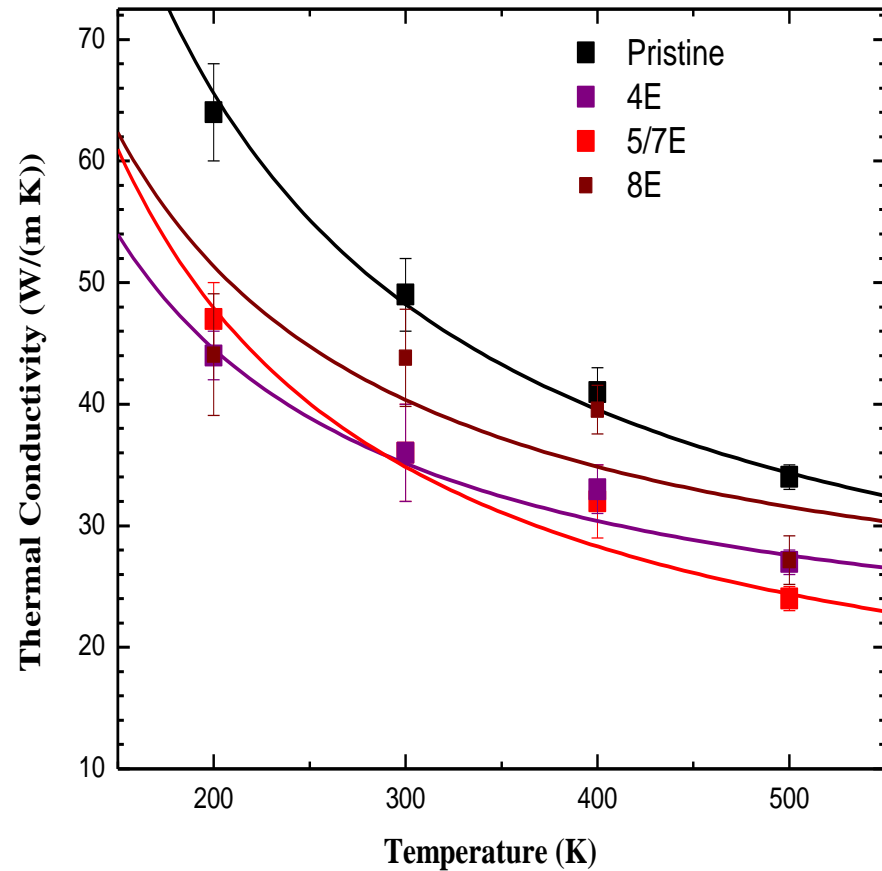
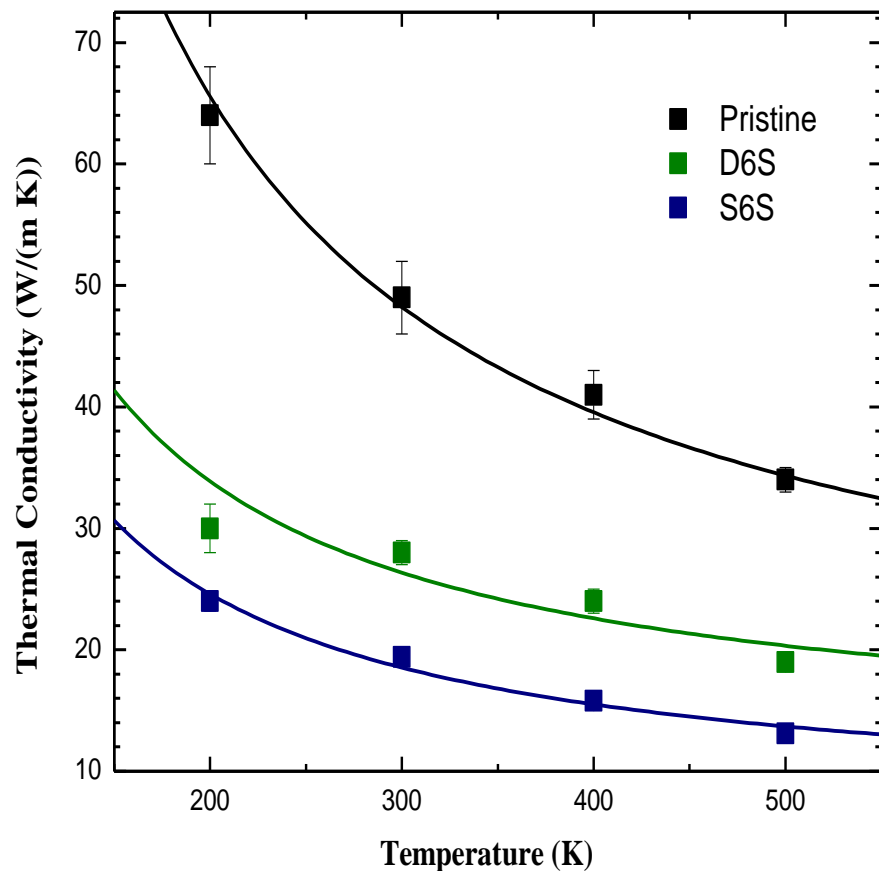
So ratio **$A_{edge}/A_{screw} = 0.53$**

TC ratio **$TC_{screw}/TC_{edge} = 0.54$**

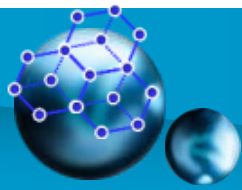
➤ The TC is inverse proportional to the elastic energy of dislocations

IV. Screw .vs. Edge dislocations

$$\kappa \sim T^{-1} A^{-j}$$



Thermal conductivity of the pristine and the two screw (a) and three edge (b) defected nanowires as the function of the temperature. The solid lines represent the above described theoretical approach.



5. Summary

□ Conclusions

❖ TC is inverse proportional to the elastic energy of dislocations. The screw dislocations having higher strain energy i.e. more strained bonds hinder the thermal transport more than the edge dislocations, which have less elastic energy - less included strain.

$$\text{ratio } A_{\text{edge}}/A_{\text{screw}} = 0.55$$

$$\text{TC ratio } TC_{\text{screw}}/TC_{\text{edge}} = 0.54$$

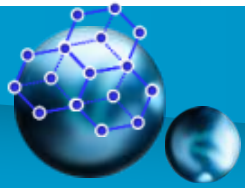
❖ The structural characteristics of the core and more specifically the coordination which characterize each individual core structure rules the corresponding J factor. Highly deformed core region => significant source of anharmonic phonon-phonon scattering Y. Ni, S. Xiong, S. Volz, T. Dumitrica PRL **113**, 124301 (2014)

$$\kappa \sim T^{-1} A^{-J}$$

❖ TC of screw dislocations < TC of edge dislocations < TC pristine

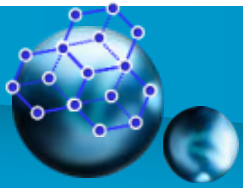
50% reduction

10% reduction



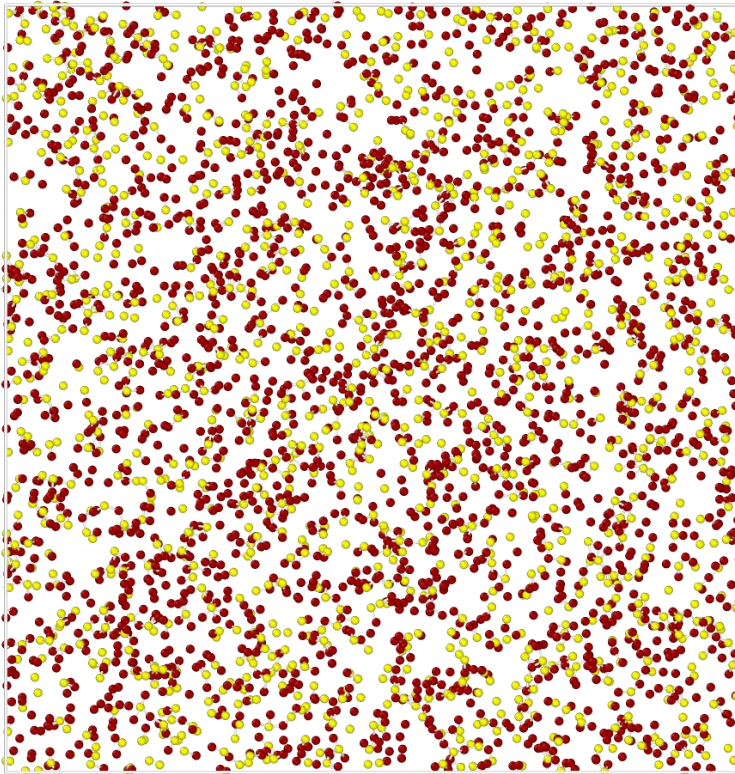
PART II:

GaN nanoclusters formation in amorphous SiO₂ matrix

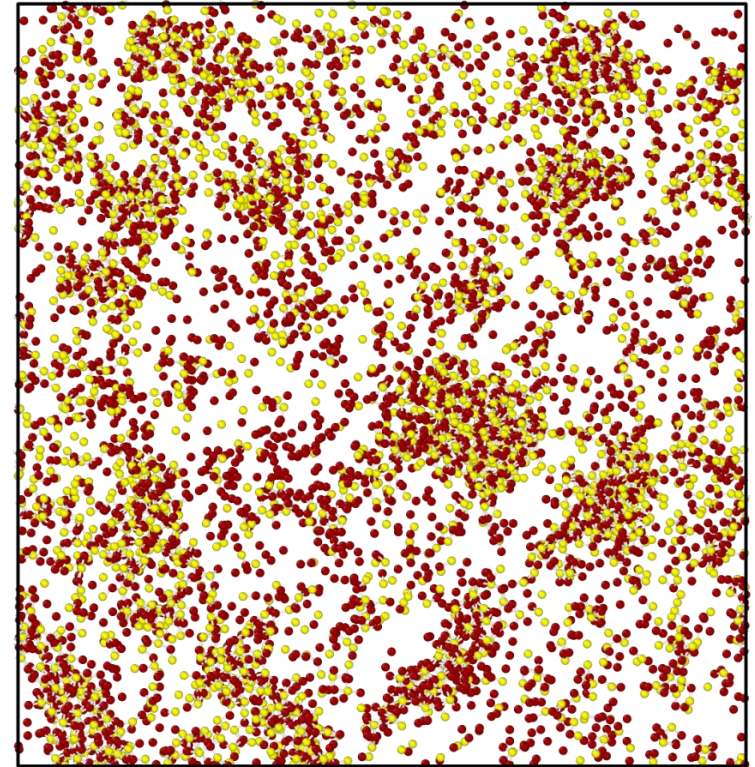


Cluster formation

1300K: SiO₂ matrix atoms removed, time = 4ns



1400K: SiO₂ matrix atoms removed, time = 4ns



For the same concentration of Vacancies

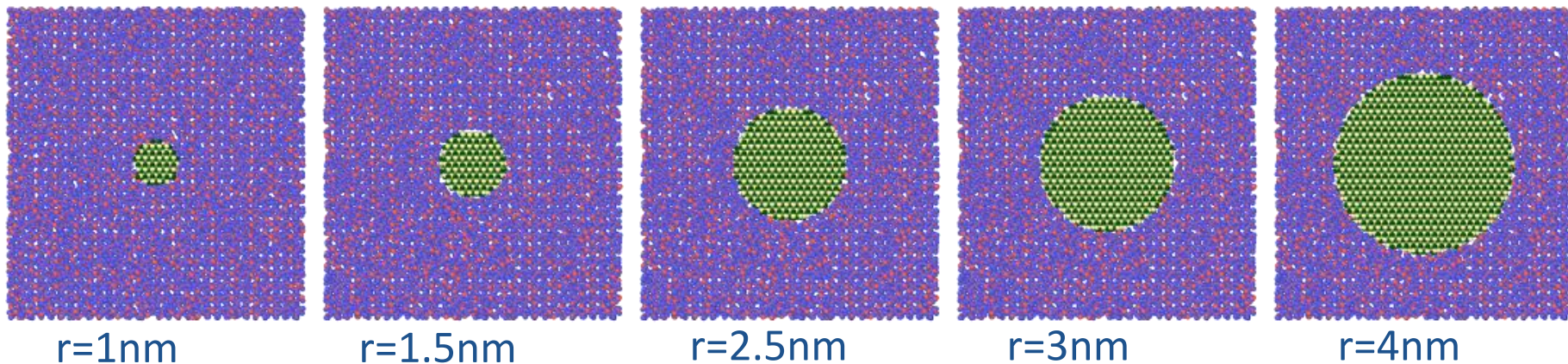




Influence of structural properties on thermal conductivity

1. Influence of **radius** on TC

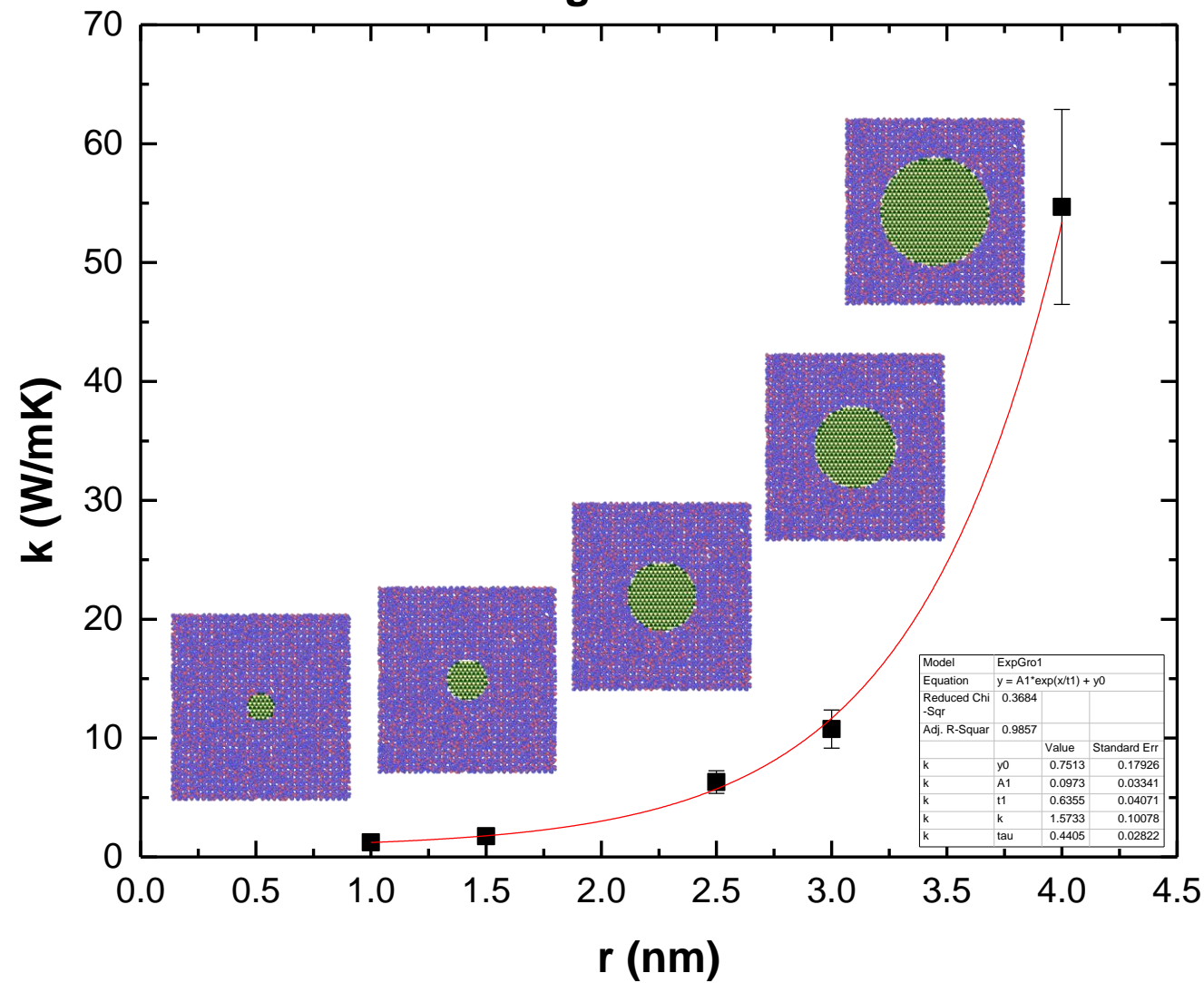
- 5 structures were created, containing a single cluster of different radius in the center
- Radiuses examined: **1nm**, **1.5nm**, **2.5nm**, **3nm** and **4nm**



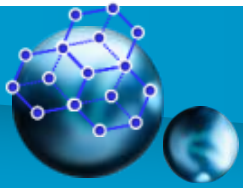


TC results

k - r for single clusters



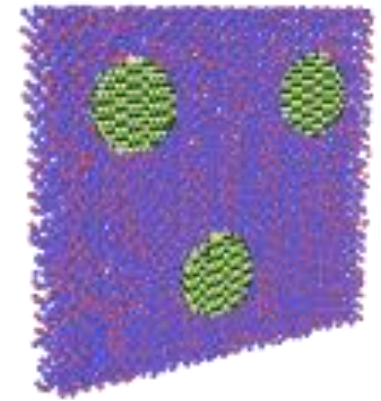
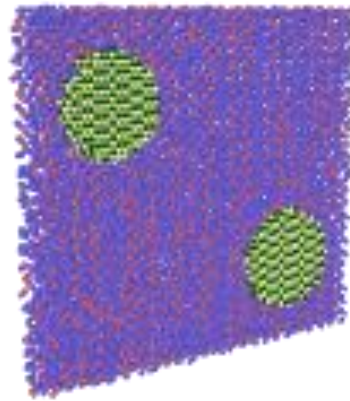
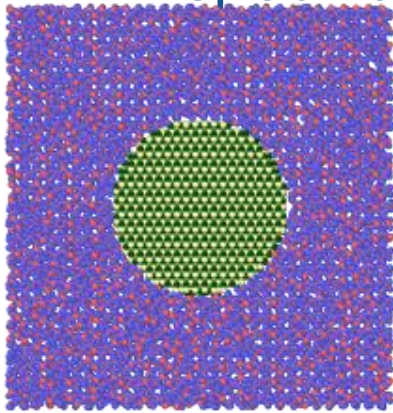
MD simulation revealed that TC is **increasing exponentially** with the increase in radius



Influence of structural properties on thermal conductivity

2. Influence of **surface** on TC

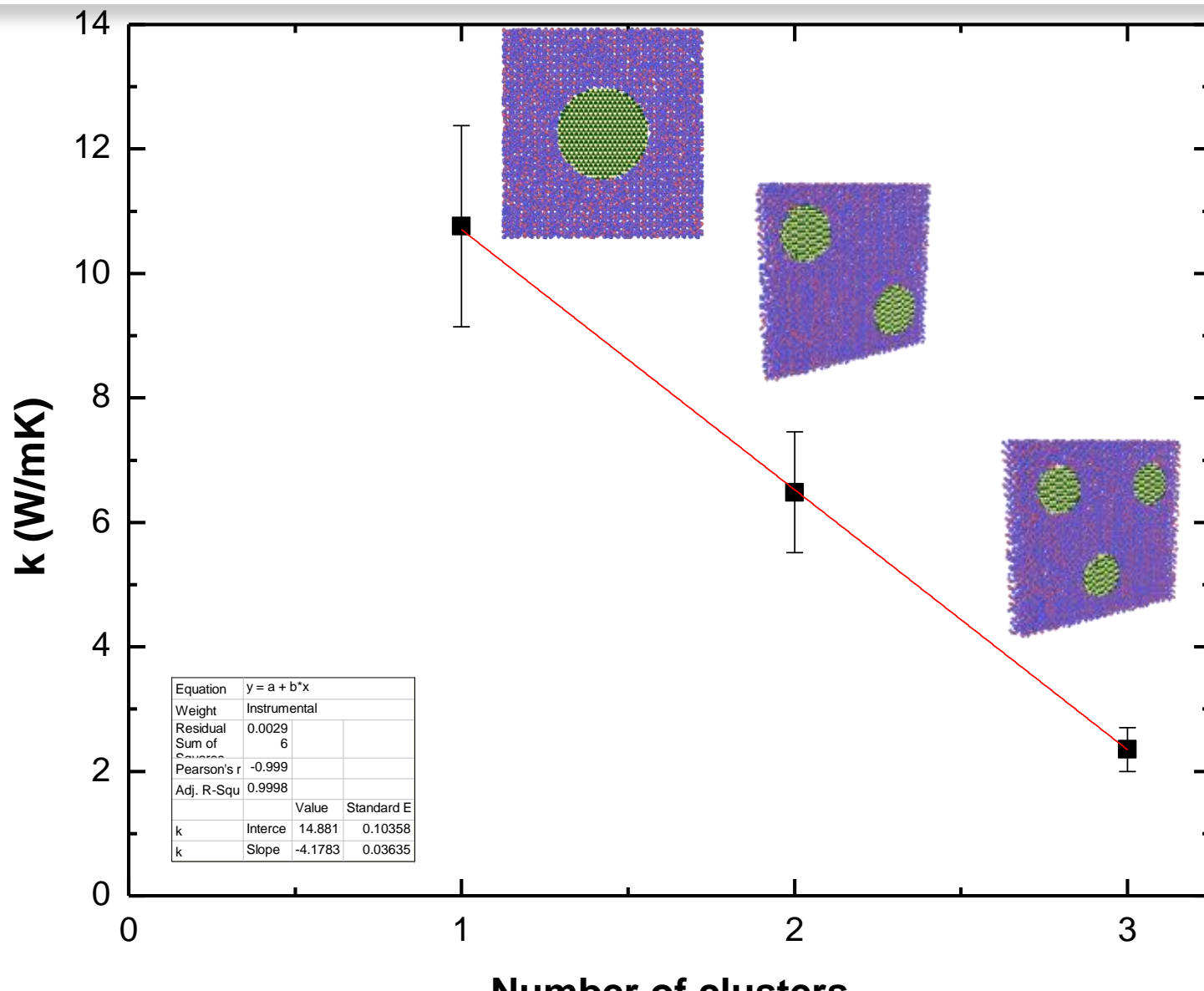
- The surface of the 3nm cluster was calculated equal to :113.097 nm²
- **Keeping constant the same total surface**, we divided the 1 cluster to 2 and 3 smaller clusters, in specific positions.





TC results

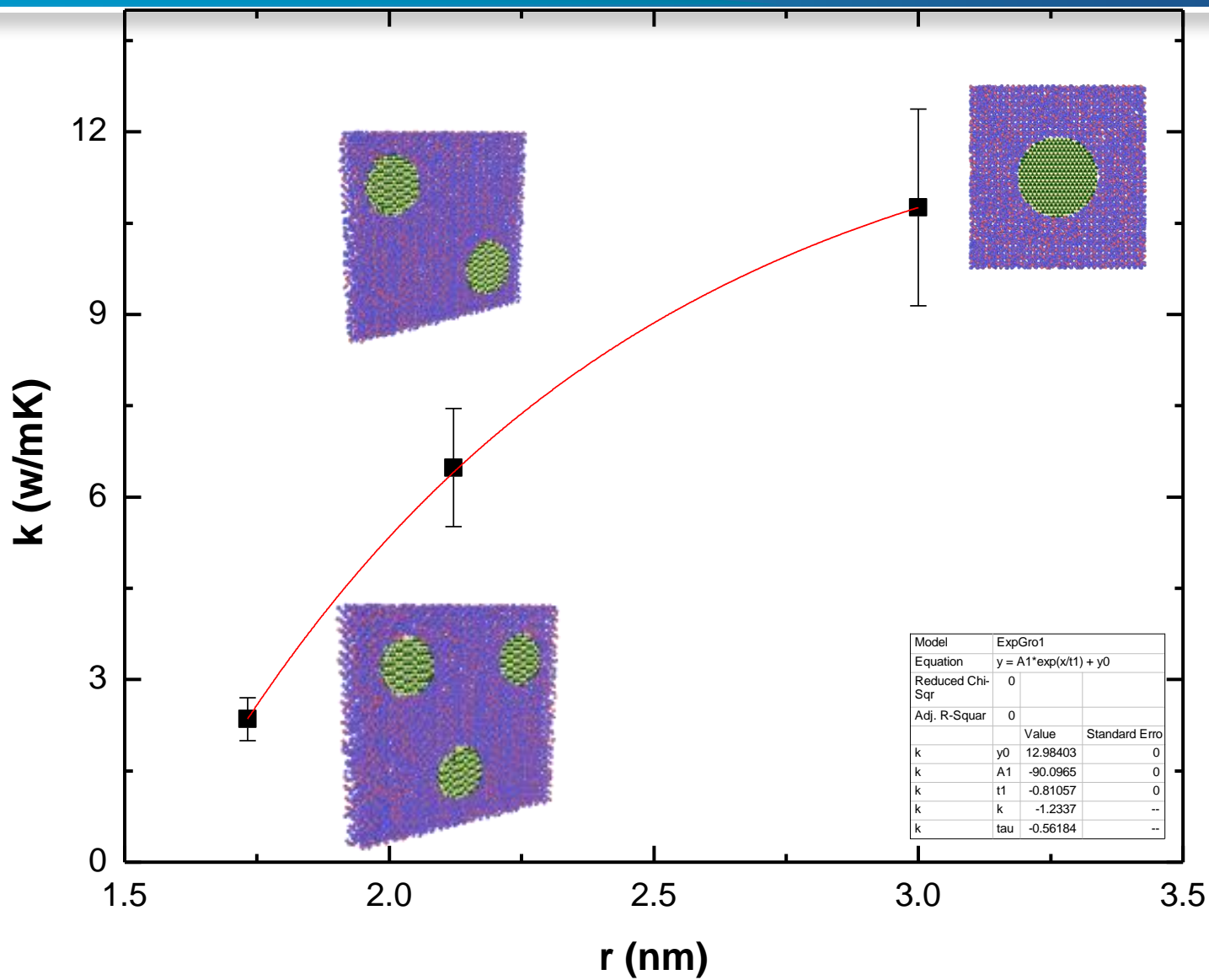
k - number of clusters for the same surface

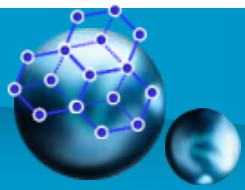




TC results

k - r for the same surface

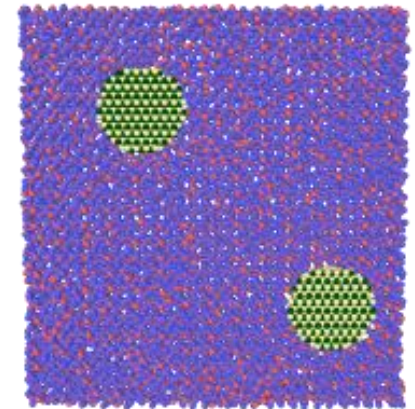
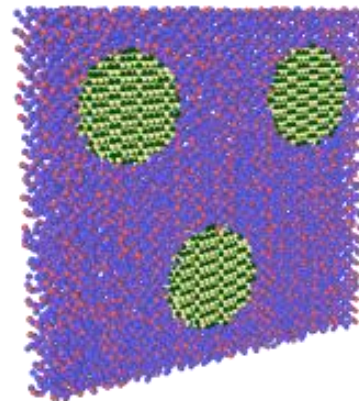
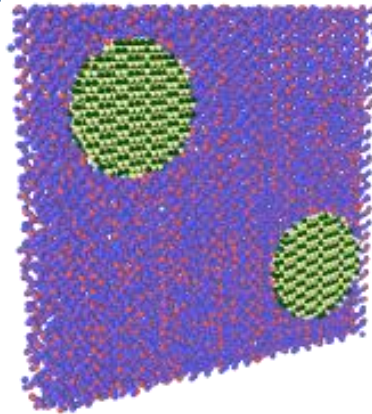
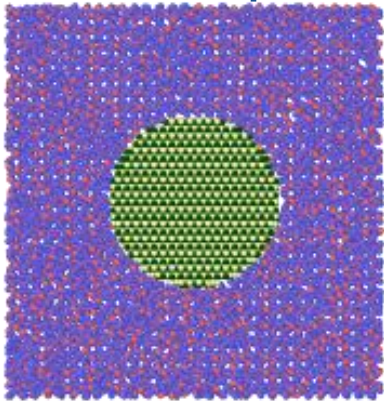




Influence of structural properties on thermal conductivity

How **volume** affects on TC?

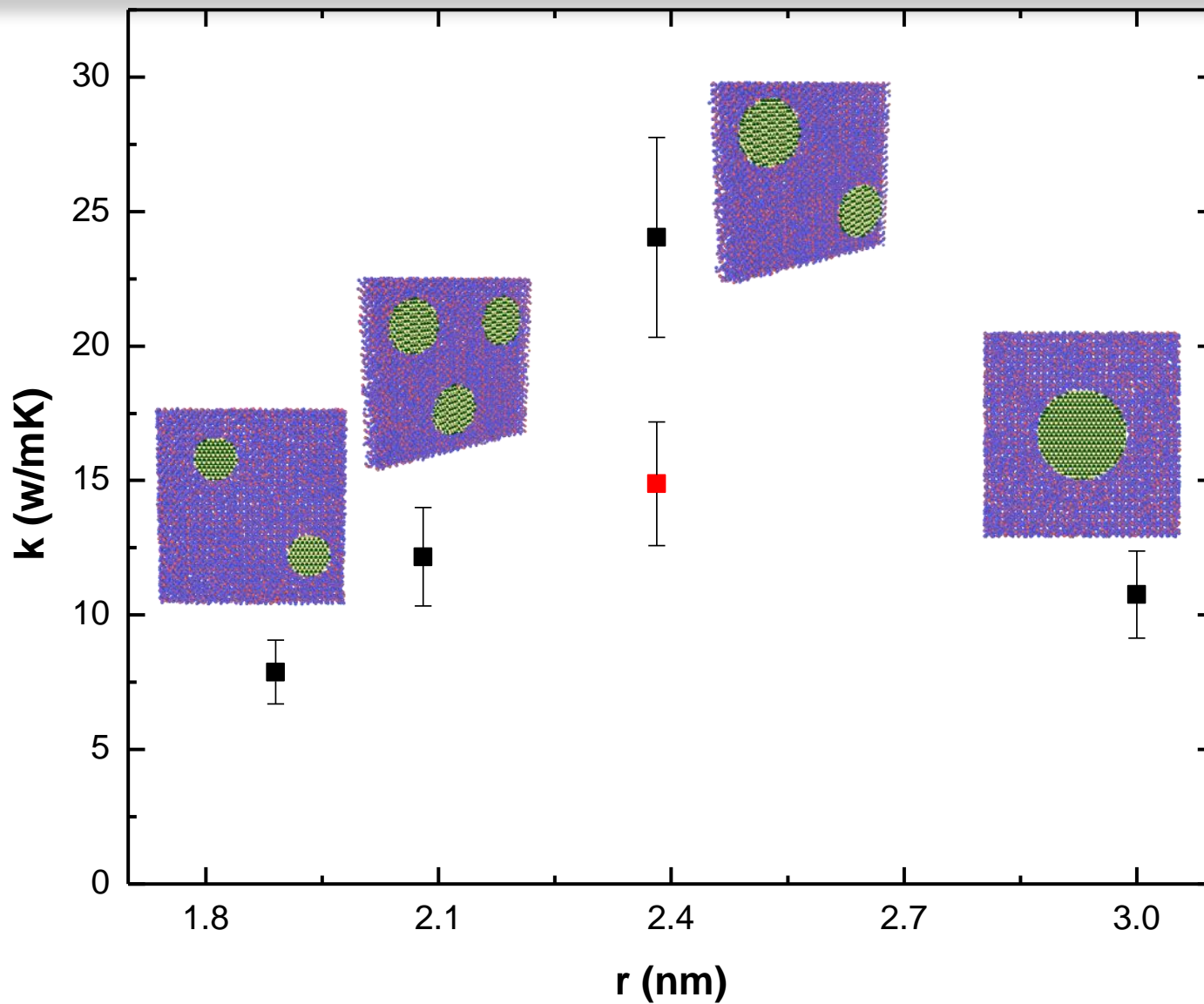
- The volume of the 3nm cluster was calculated equal to: **113.1 nm³**
- **Keeping constant the cluster's total volume**, we divided 1 cluster to 2, 3 and 4 smaller clusters, in specific positions

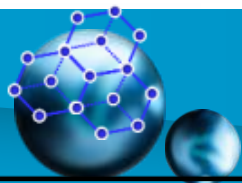




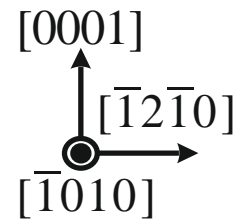
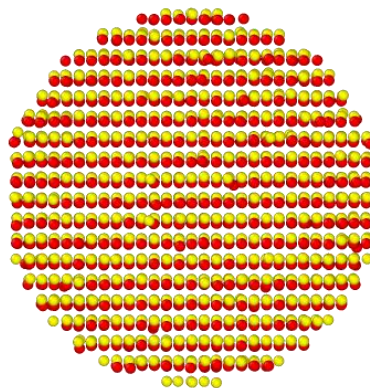
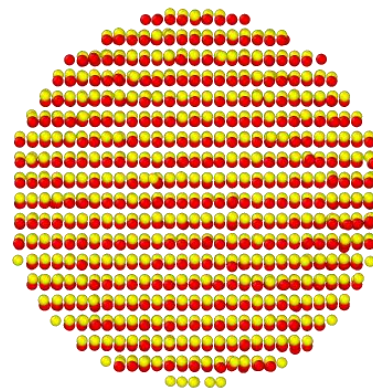
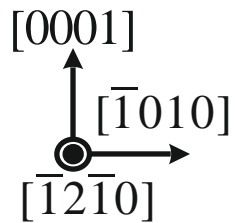
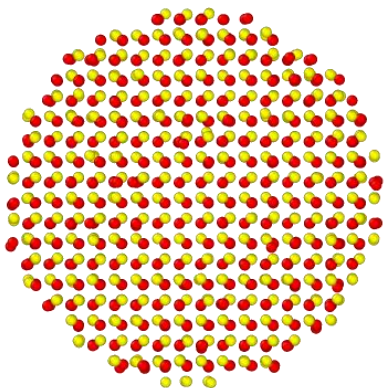
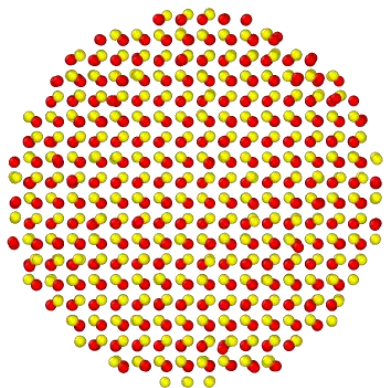
TC results

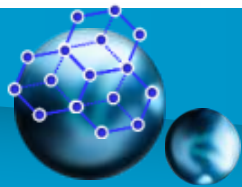
k - r same volume





TC results





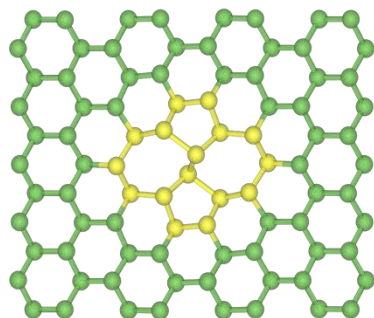
PART III:

Defects in novel 2D materials-ARSENENE

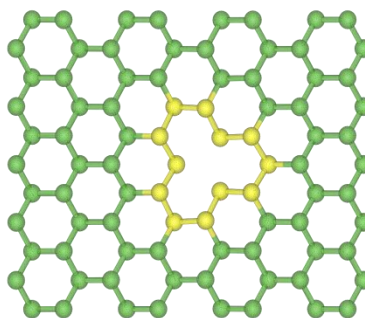


Structural & Energetic properties of defective buckled arsenene

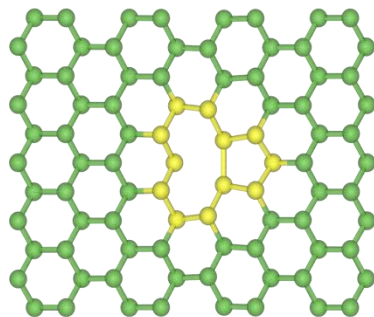
SW, $E_{\text{for}} = 1.22\text{eV}$



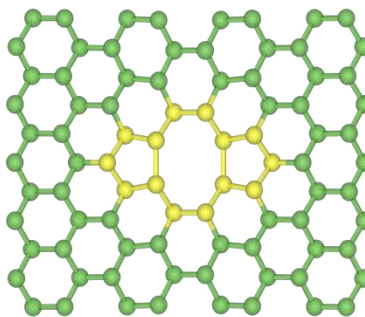
SV, $E_{\text{for}} = 2.22\text{eV}$



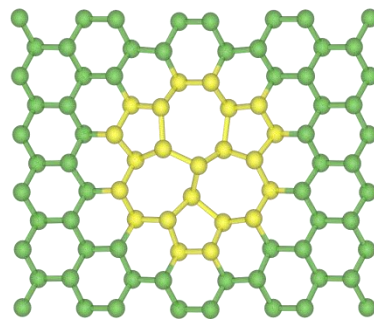
SV-59, $E_{\text{for}} = 2.01\text{eV}$



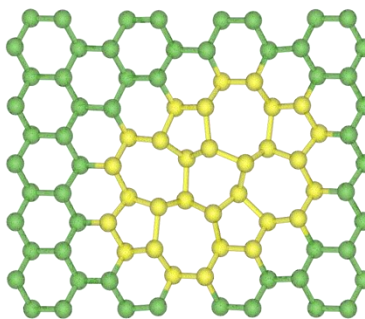
DV-585, $E_{\text{for}} = 2.27\text{eV}$



DV-555-777, $E_{\text{for}} = 2.26\text{eV}$

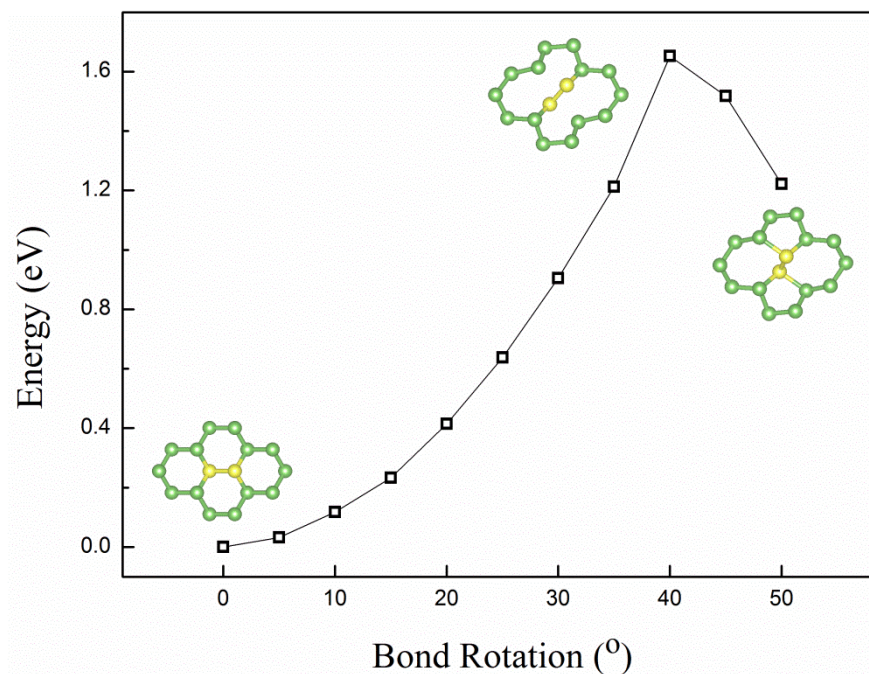


DV-5555-6-7777, $E_{\text{for}} = 2.81\text{eV}$



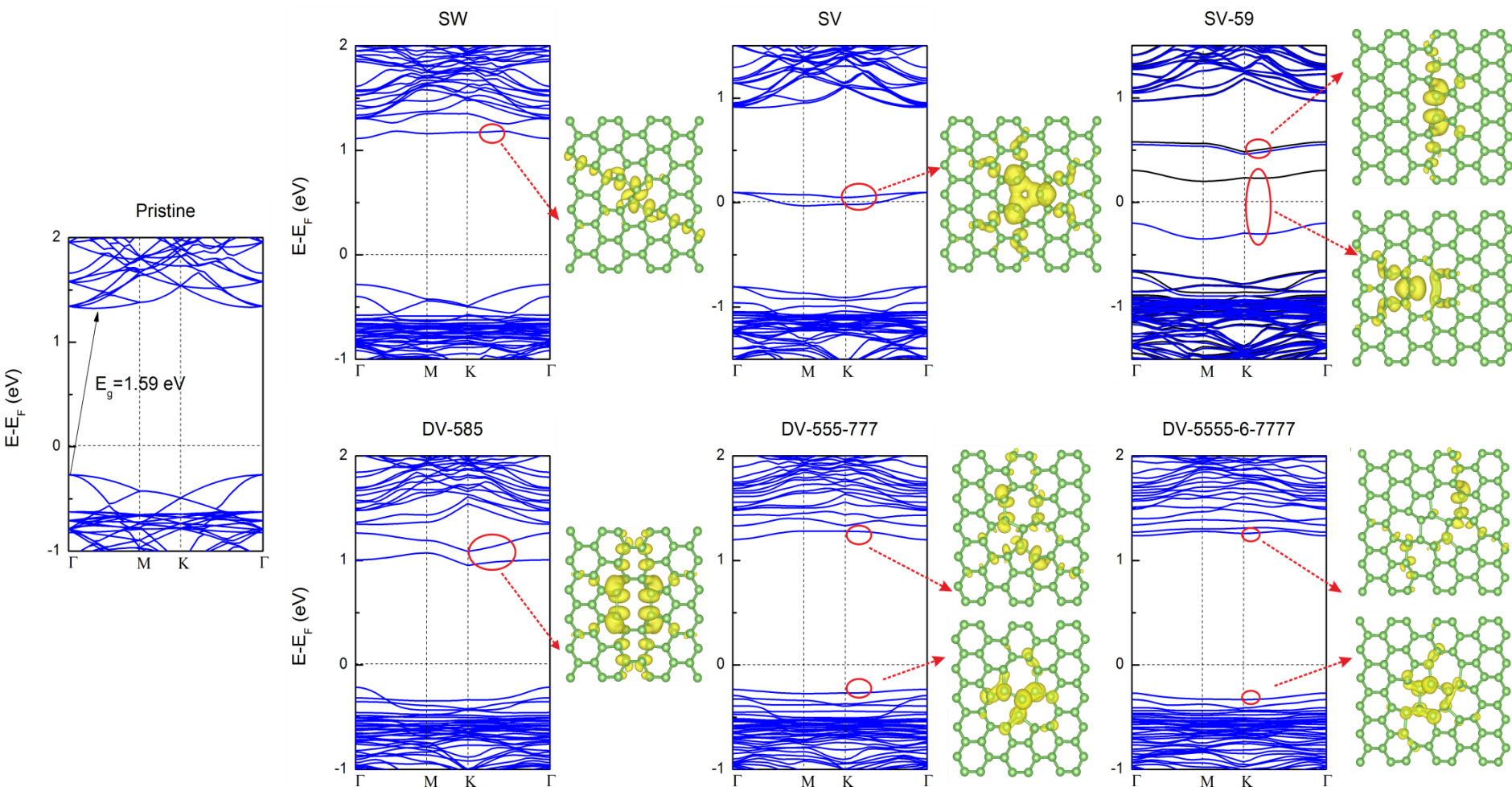


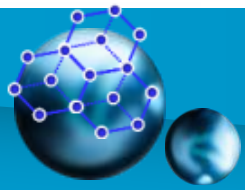
Energetics of SW defect creation in buckled arsenene





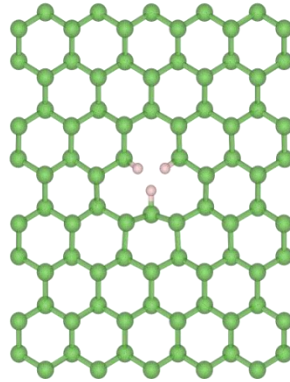
Electronic properties of defective buckled arsenene



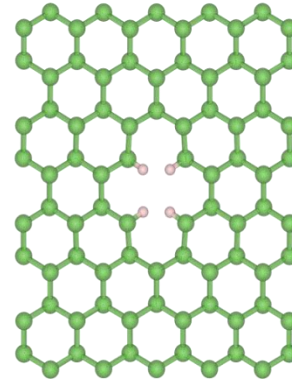


H-passivated defective buckled arsenene

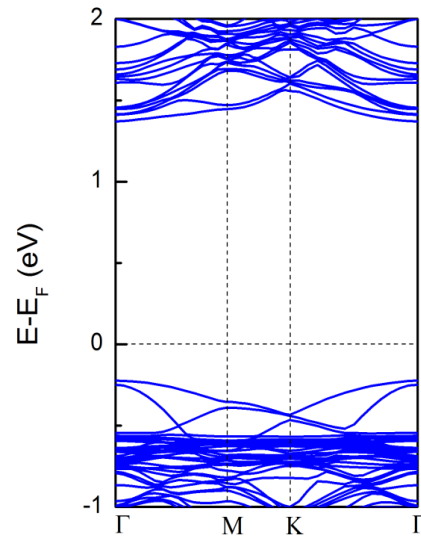
SV-3H, $E_{\text{for}}=0.97$ eV



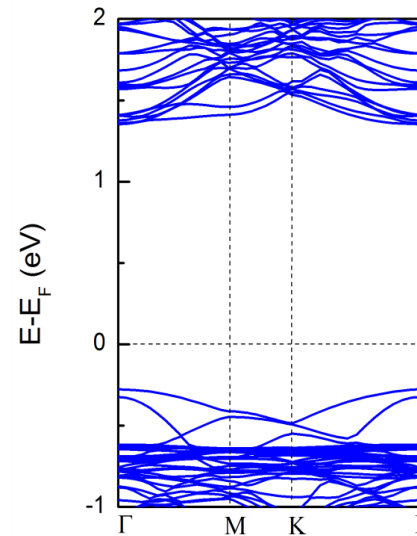
DV-4H, $E_{\text{for}}=1.11$ eV



SV-3H



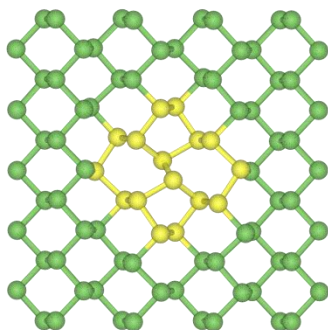
DV-4H



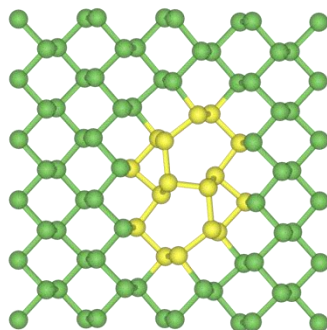


Structural & Energetic properties of defective puckered arsenene

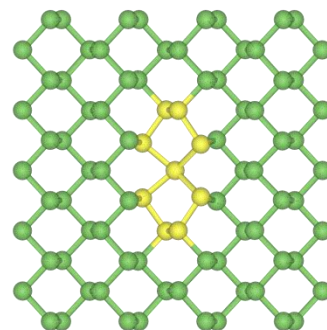
SW-1, $E_{\text{for}}=0.68$ eV



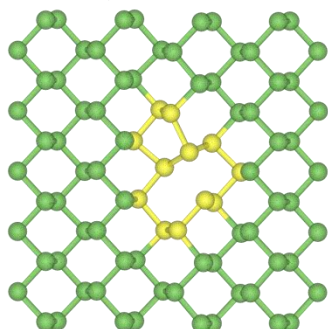
SW-2, $E_{\text{for}}=1.18$ eV



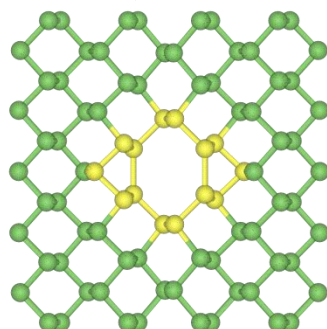
SV-55-66, $E_{\text{for}}=1.46$ eV



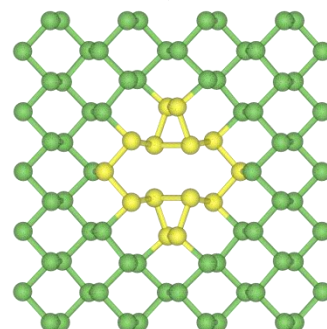
SV-59, $E_{\text{for}}=1.24$ eV



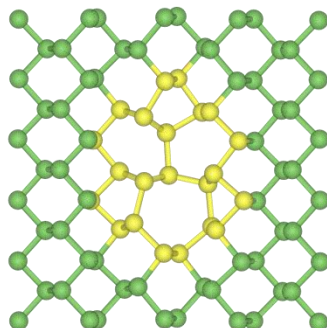
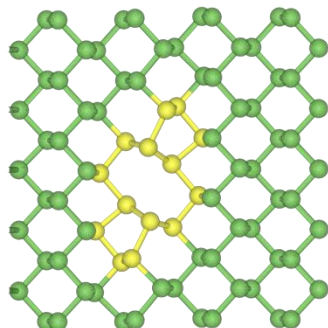
DV-585-1, $E_{\text{for}}=2.42$ eV



DV-4-10-4, $E_{\text{for}}=1.24$ eV

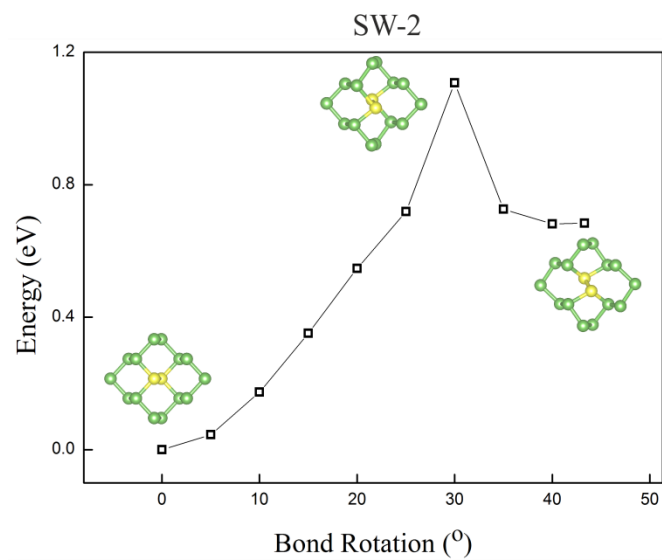
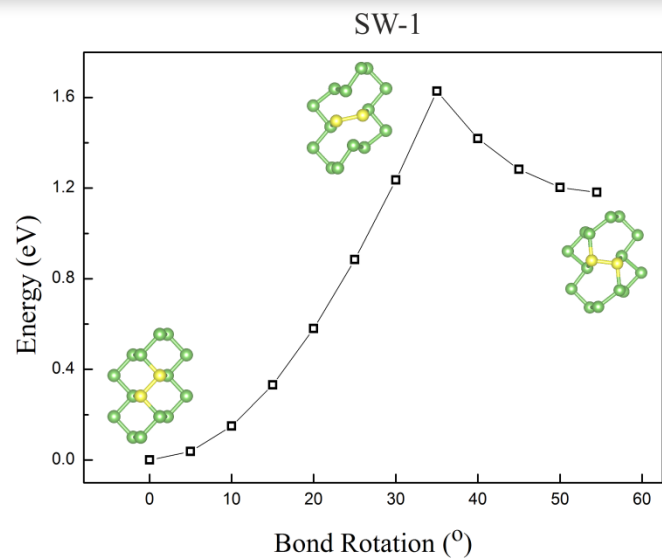


DV-585-2, $E_{\text{for}}=1.01$ eV



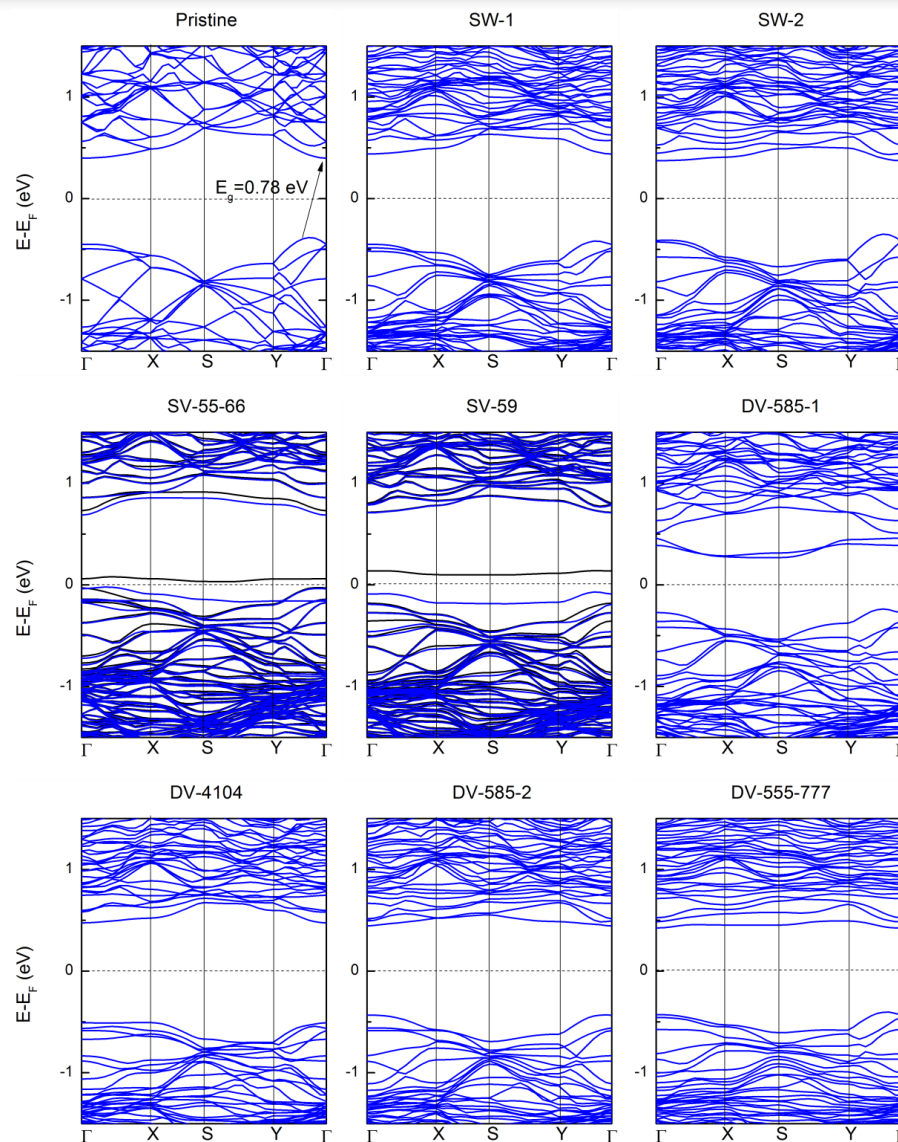


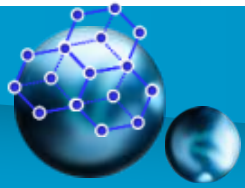
Energetics of SW defects creation in puckered arsenene





Electronic properties of defective puckered arsenene



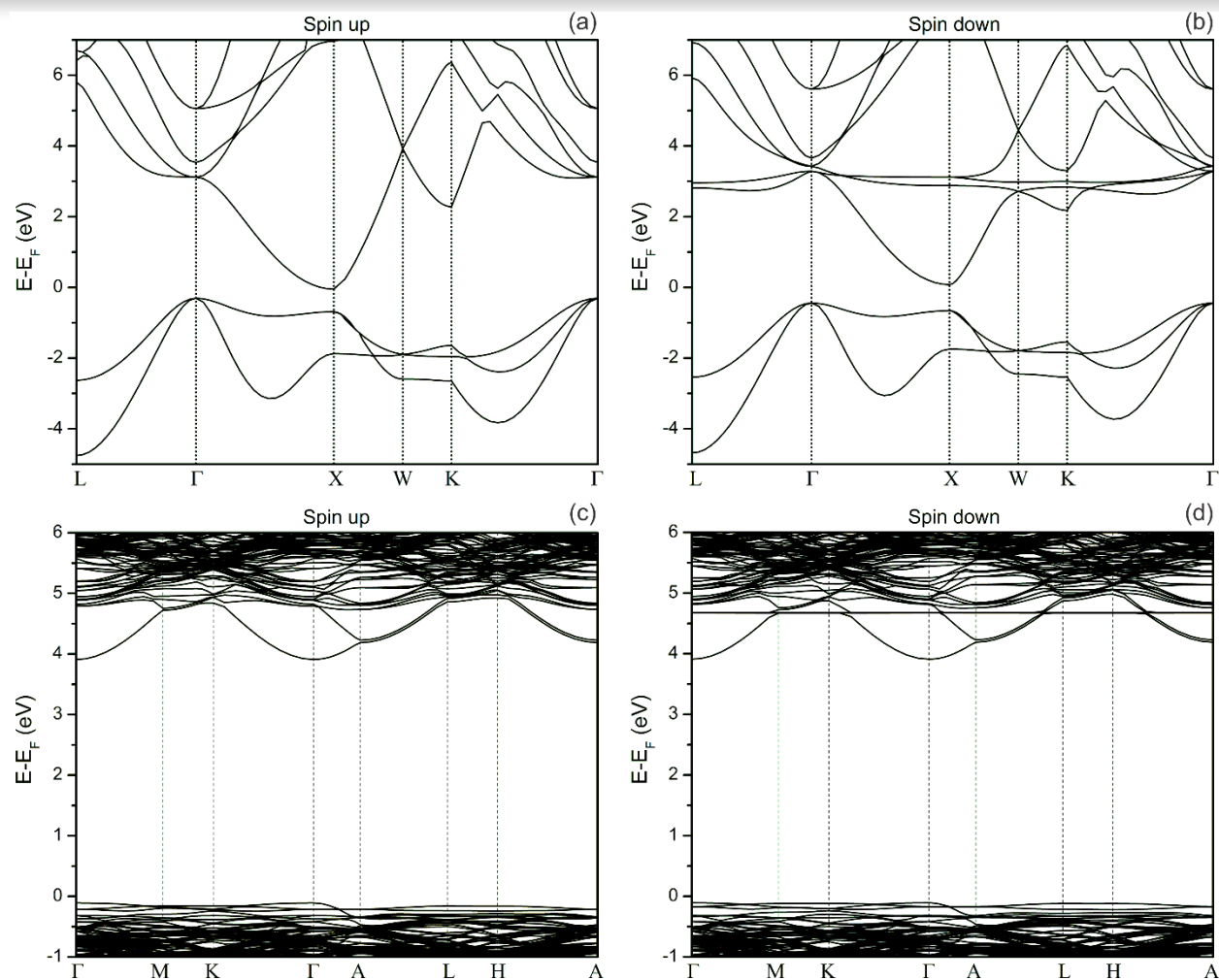


PART IV:

Ab initio investigation of the AlN:Er system



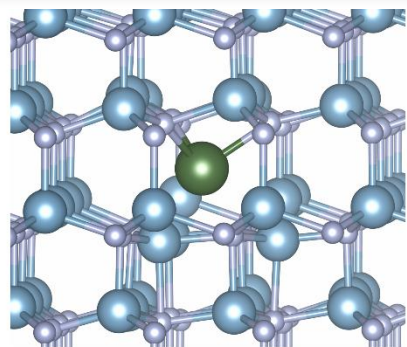
DFT+U for RE nitrides



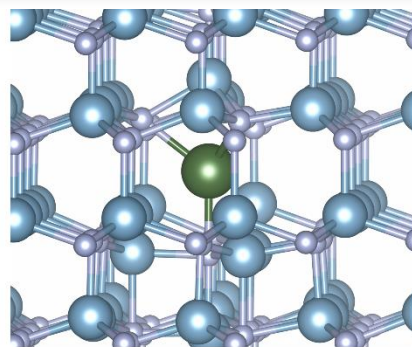
The spin-resolved bandstructures of (a)-(b) rocksalt ErN and (c)-(d) AlN:Er_{Al} for $U_{eff}=8.6$ eV. The Fermi level is at 0 eV.



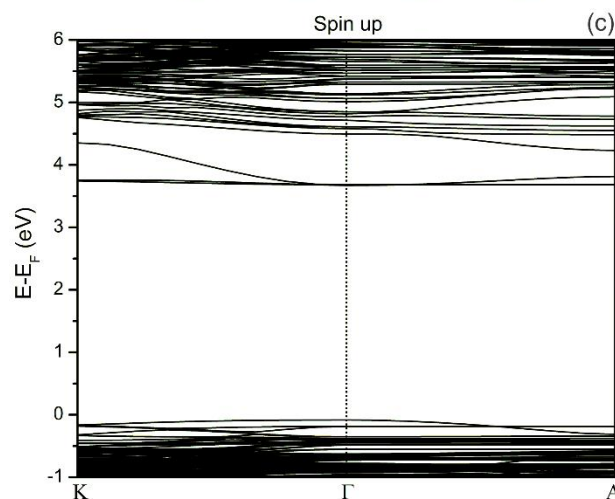
Octahedral - Tetrahedral



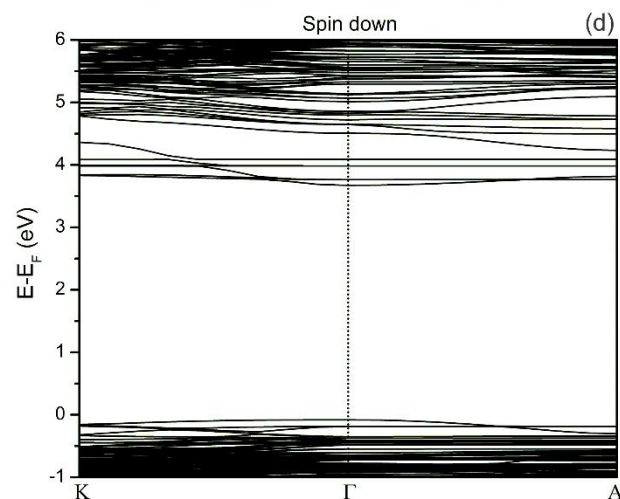
(a)



(b)



(c)



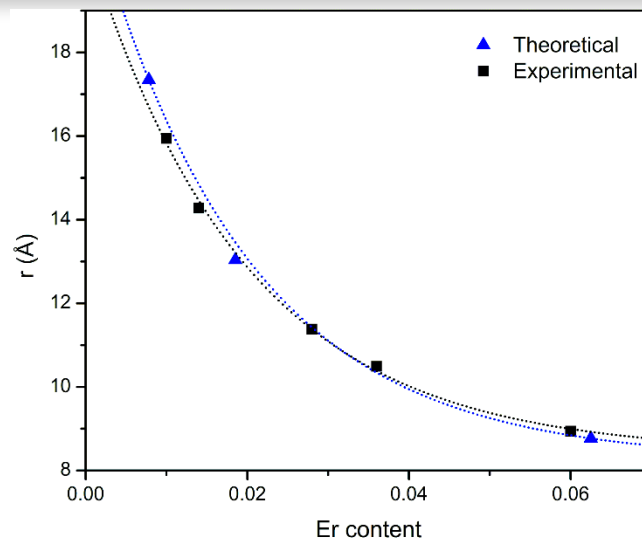
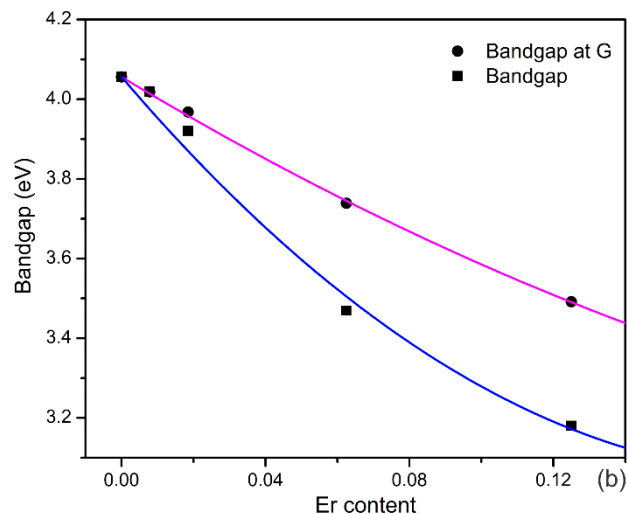
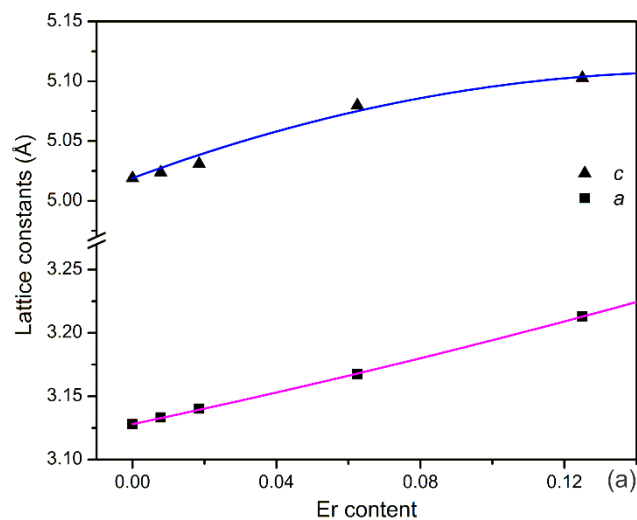
(d)

Charge state	$Er_{i,O}$	$Er_{i,T}$
0	11.92	14.14
+1	8.31	10.22
+2	4.33	6.77
+3	0.62	3.86

The (a) $Er_{i,O}$ and (b) $Er_{i,T}$ localizations in the AlN wurtzite structure after the relaxations for a +3 charge state. Small silver spheres represent N atoms, big blue spheres Al atoms, and the biggest green spheres correspond to Er atoms. (c) and (d) The spin-resolved bandstructure of AlN: $Er_{i,O}$. The defect charge is +3.



Structural analysis

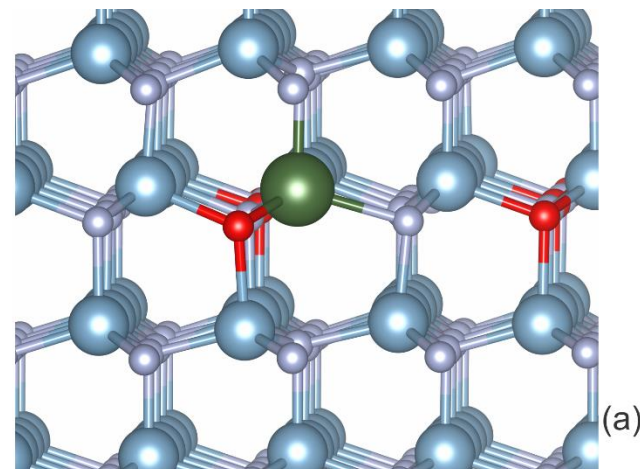
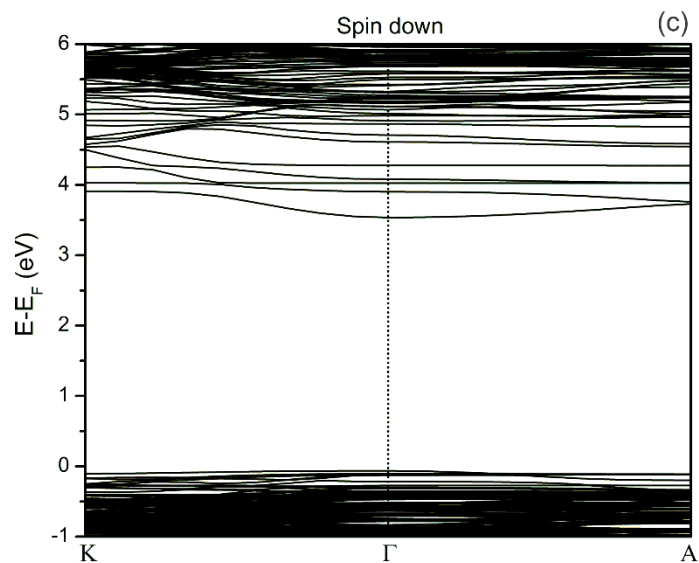
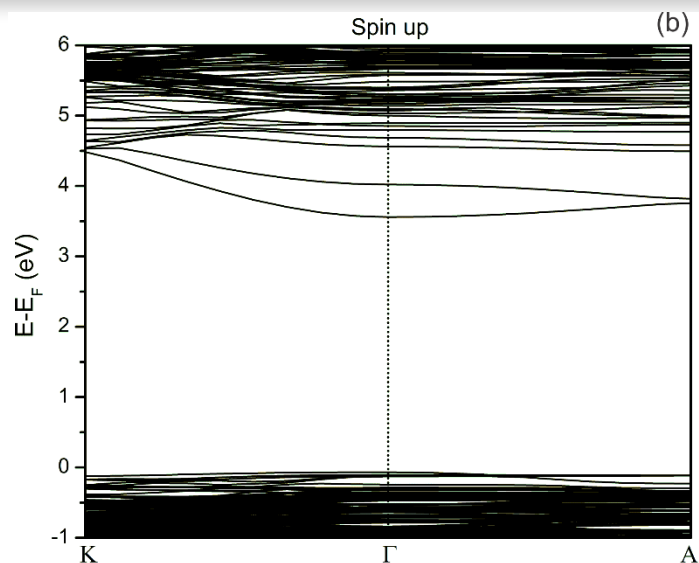


The average distance r between two Er atoms calculated using experimental and theoretical results as a function of the Er content. The corresponding dotted curves are exponential decay fits on the two sets of data.

(a) The a (rectangles) and c (triangles) lattice constants of the $\text{Er}_x\text{Al}_{1-x}\text{N}$ alloys as a function of the Er content and (b) the bandgaps of the $\text{Er}_x\text{Al}_{1-x}\text{N}$ alloys as a function of the Er content. The blue and magenta curves are a second order polynomial fit according to the quadratic Vegard's law.



$\text{Er}_x\text{Al}_{1-x}\text{N}_y\text{O}_{1-y}$



(a) The preferable configuration for $\text{Er}_{0.01}\text{Al}_{0.99}\text{N}_{0.94}\text{O}_{0.06}$. Small silver spheres represent N atoms, small red spheres O atoms, big blue spheres Al atoms, and the biggest green spheres correspond to Er atoms. (b)-(c) the corresponding spin-resolved bandstructures. A charge of +1 per O atom is considered.



Collaborators

PART I: The influence of edge and screw dislocations of wurtzite GaN on the thermal conductivity

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PART II: GaN nanoclusters formation in amorphous SiO₂ matrix

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PART Iii: Defects in novel 2D materials-ARSENENE

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PART IV: Ab initio investigation of the AlN:Er system

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Thank you for your attention